



This document contains the confidential and proprietary information of Nanotronics Imaging, Inc. Neither this document nor any of the information contained is to be reproduced, distributed, used or disclosed, either in whole or in part, except as specifically authorized by Nanotronics Imaging, Inc.

nSpec Version 0.21.1.0

Release Date: 10 Mar 2022

Documentation Updated: 09 Sep 2022


Major Features: GDS Masking, Configurable Light Tower, Bare Wafer Alignment for Device Inspection

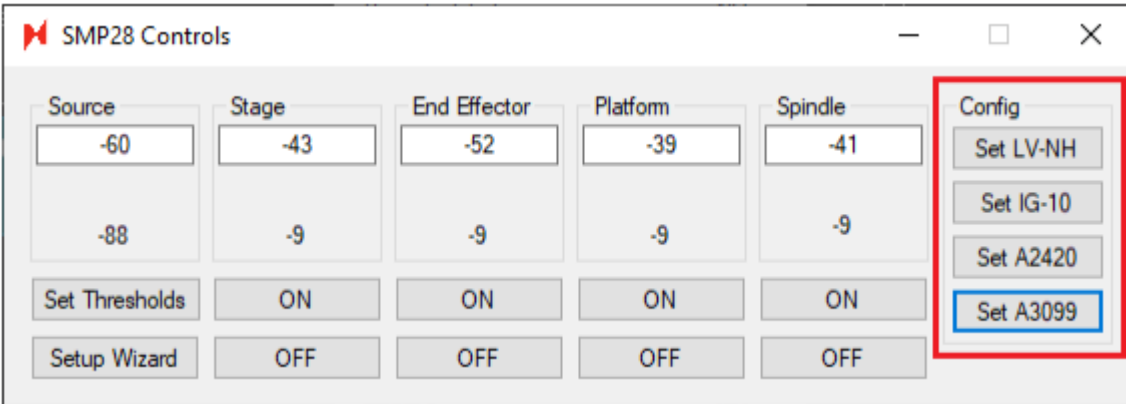
- [Overview](#)
- [Upgrading to v0.21.1.0](#)
- [Major Enhancements](#)
 - [Overview](#)
 - [Interface](#)
 - [Workflows](#)
 - [Classic Device Masks Workflow \(Export Mode = Horizontal/Vertical Tiles\)](#)
 - [Custom Device Masks Workflow \(Export Mode = Single Image \(no Tiling\)\)](#)
- [New Features](#)
 - [Highlights](#)
 - [Manual Defect Classification Correction Support](#)
 - [Running Single Classification Change \(Single Tile view in nView\):](#)
 - [Running Group Classification Change \(Multi Tile view in nView\):](#)
 - [Configurable Light Tower Support](#)
 - [Dual-Flat Bare Wafer Alignment Support](#)
 - [Device Inspection on Bare Wafer Support](#)
 - [SECS/GEM Upgrades:](#)
 - [General Improvements](#)
 - [Scanning Improvements](#)
 - [Analysis Improvements](#)
 - [Autoloader Improvements](#)
 - [New Features Changelog](#)
- [Bug Fixes](#)
 - [Changelog](#)

Overview

This version includes many features that didn't quite make it into v21.0.0 after many months of release candidate cycle testing held up that build. As a result, there are a large spread of features and functionality in this build that while they weren't necessarily tied to urgent deliverables, were deemed to be valuable for customer release by the product team.

Upgrading to v0.21.1.0

 Required Library Update



Autoloader 2s with a Generation 3 prealigner assembly (P/N: 3099) will need to have their Arduinos flashed by the latest TSToolKit software. This is in addition to the flash required for generation 3 aligner lasers. The exlog will show these values during initialization. The program option as of v0.21.1.0:

- For aligner lasers:
 - Gen2 do not need to be flashed (nSpec already assumes LV-NH)
 - Gen3 need to be flashed with IG-10
- For prealigners:
 - Gen2 do not need to be flashed (nSpec already assumes A2420)
 - Gen3 need to be flashed with A3099

Autoloader 2s with a Generation 3 prealigner will perform an automatic search for its starting position, which will now be written to the exlog.

The default Device Inspection parameter - *Golden Template Processing Batch Size* - has been updated to -1. The process value of this parameter is not affected when upgrading. -1 is now recommended.

For tools with a bonito camera, the recommended value for *Frame Refresh Limit (FPS)* is -1 (free run mode) and the recommended value for *Camera Acquisition Frame Rate Limit (Frames Per Second)* is -1 (free run mode). If you experience performance issues with nSpec when using these values, you may set hard limits to these options.

Major Enhancements

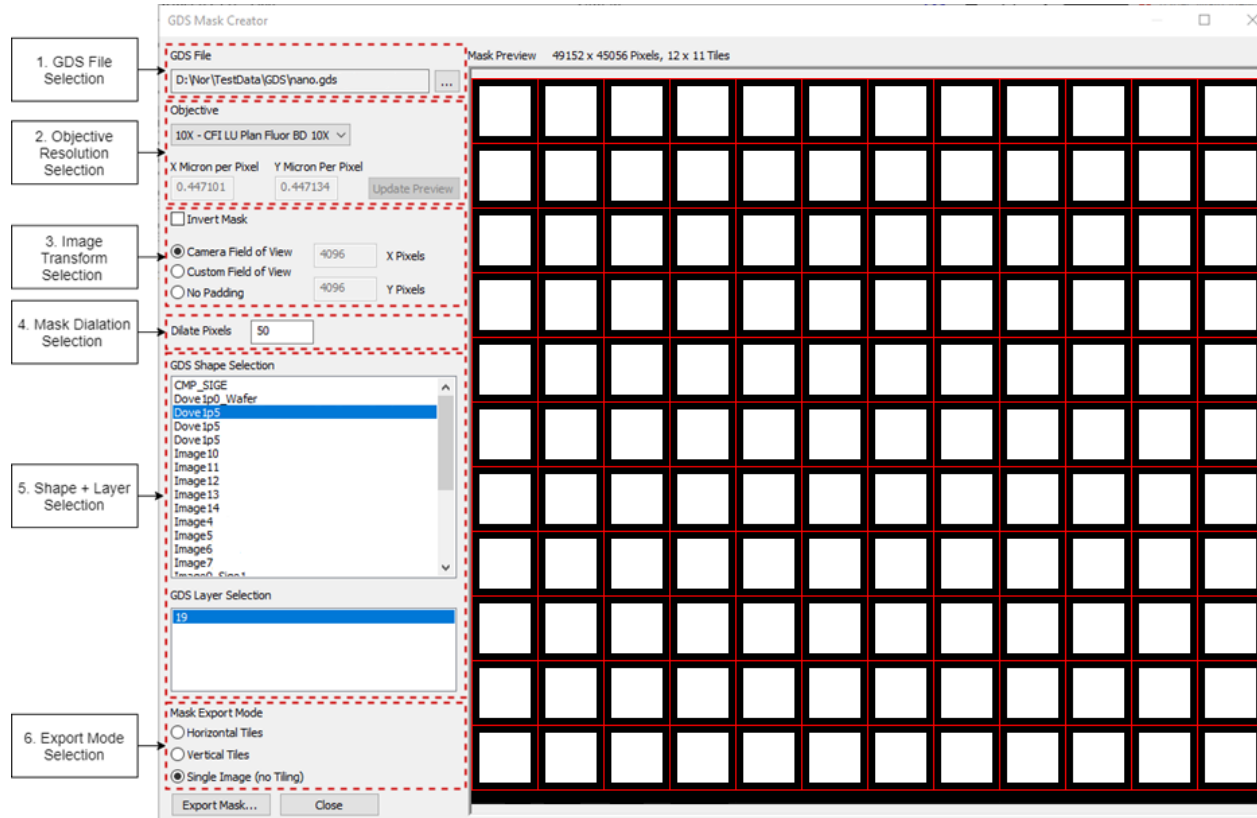
GDS Masking

- [Overview](#)
- [Interface](#)
- [Workflows](#)
 - [Classic Device Masks Workflow \(Export Mode = Horizontal/Vertical Tiles\)](#)
 - [Custom Device Masks Workflow \(Export Mode = Single Image \(no Tiling\)\)](#)

Overview

nSpec now has a built-in utility for creating device inspection masks for *Calma GDSII* files - the *GDS Mask Creator*. This utility is accessible from *Main View / Stage View Utility GDS Mask Creator...*

Interface



| Control | Description | Usage |
|---------------------------------------|--|--|
| GDS File Selection | Sets a compatible Calma GDSII file | Select file used to create device layout |
| Objective Resolution Selection | Sets X/Y Micron per Pixel | Select objective used when creating device scan |
| Image Transform Selection | Color inverts and pads the entire image. | Select Camera Field of View |
| Mask Dilation Selection | Increases the number of pixels surrounding a shape's layer | 0 is fine, but can be increased for more coverage |
| Shape + Layer Selection | Sets shape and layer to mask | Select shape (and appropriate layer(s)) used to create device layout |
| Export Mode Selection | Sets the mask export mode | See Workflow below |
| Mask Preview | Shows what the exported mask will look like when exported | |

Workflows

The *GDS Mask Creator* can be used to create classic device masks (mask linked to device templates) and custom masks. **Scans that include >100 template files must use the [Classic Device Masks Workflow](#).**

Classic Device Masks Workflow (Export Mode = Horizontal/Vertical Tiles)

A large mask can be sliced into individual masks during export by selecting the *Horizontal Tiles* or *Vertical Tiles* export modes before exporting. When set to *Horizontal Tiles*, the mask is sliced based off the horizontal movement of the stage during a device scan. When set to *Vertical Tiles*, the mask is sliced based off the vertical movement of the stage during a device scan. The export mode should be chosen based on the type of scan being run:

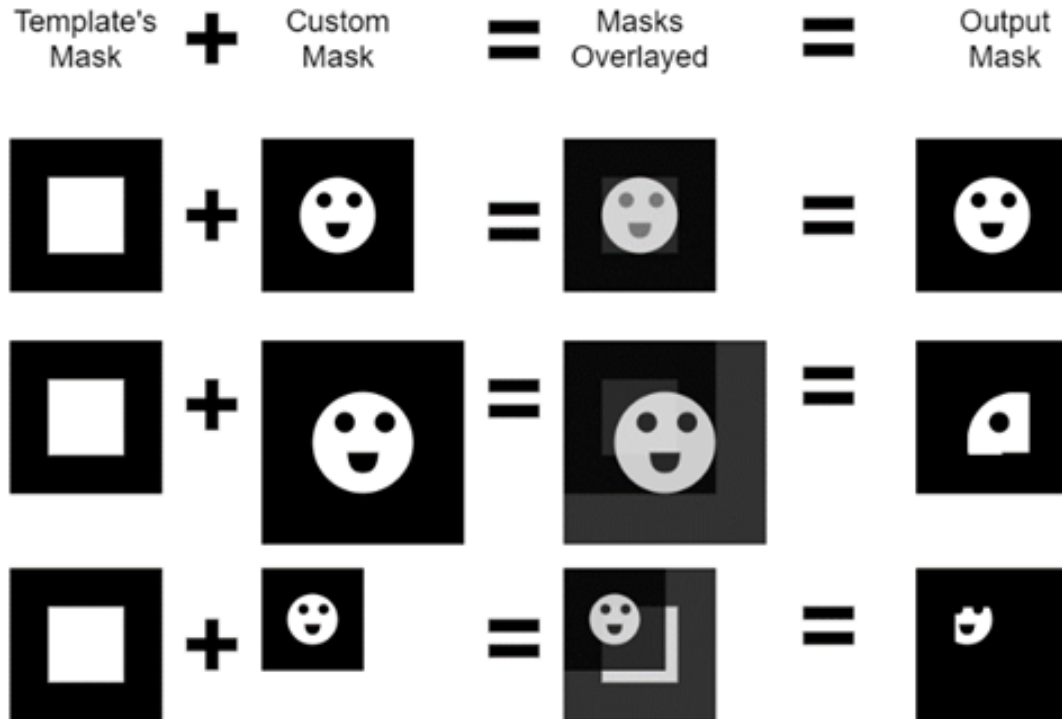
| Scan Type | Export Mode |
|--|-------------------------|
| Continuous Scan | <i>Horizontal Tiles</i> |
| Stop & Go scan with the program option Path Optimization = 0 | <i>Horizontal Tiles</i> |
| Stop & Go scan with the program option Path Optimization = 1 | <i>Vertical Tiles</i> |

After clicking *Export Mask...* in the *GDS Mask Creator*, you must set the mask's filename as your target template's filename. For example, if your target template is *nano_demo_0001_template.png*, then your mask's filename should be *nano_demo.png*. After exporting, you may overwrite your template's mask(s). **Warning: If you export into the directory containing your target template, there will be no prompt to confirm overwrite of existing masks.**

Custom Device Masks Workflow (Export Mode = Single Image (no Tiling))

A new parameter has been added to the *Device Inspection* analyzer - *Custom Device Mask*; masks exported with the *Single Image (no Tiling)* export mode (using this workflow) will be specified using this parameter. Custom masks are used in addition to template masks. Specifically, custom masks are template masks are combined, before image analysis, to create an output mask. An output mask is created with the following method:

- The custom mask is sliced depending on the number of template masks
 - If a template is only one image, then the custom mask is not sliced
 - If a template has n images, the custom mask will be sliced into n individual custom masks, where each individual custom mask lines up with its corresponding template mask
- Each custom mask and template mask are lined up top-left corner to top-left corner
- Each output pixel is the result of a logical AND operation between the template and custom masks' pixels
 - Output pixels can only be white if both the pixel from the custom mask and the template mask are white. If either pixel is black (or both are black), the output pixel is black
- Each output mask is cropped to the dimensions of the template mask



Bare Wafer Alignment - Dual Flat Support

In version 0.21.0.0 we enabled Bare Wafer Alignment - a new type of scan alignment that intelligently detects where the wafer sits on the stage, identifies the wafer flat or notch, and then aligns the scan with the alignment feature positioned at one of the cardinal positions. This update adds support for dual flats.

Autoloader Alignment Improvements

A number of autoloader alignment improvements have gone into this build. In general, the autoloader should be more stable when wafer notches are placed onto the pre-aligner with slight offsets.

Camera Performance & Stability Improvements

This body of work sets the stage for higher throughput scanning.

New Features

- [Highlights](#)
 - [Manual Defect Classification Correction Support](#)
 - [Running Single Classification Change \(Single Tile view in nView\):](#)
 - [Running Group Classification Change \(Multi Tile view in nView\):](#)
 - [Configurable Light Tower Support](#)
 - [Dual-Flat Bare Wafer Alignment Support](#)
 - [Device Inspection on Bare Wafer Support](#)
 - [SECS/GEM Upgrades:](#)
 - [General Improvements](#)
 - [Scanning Improvements](#)
 - [Analysis Improvements](#)
 - [Autoloader Improvements](#)

- [New Features Changelog](#)

Highlights

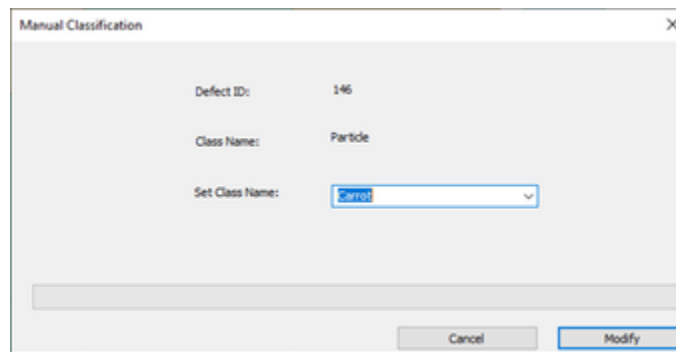
Manual Defect Classification Correction Support

Users can now manually reclassify defects in nView.

Note, for *Group Classification Changes*, there is a known issue where attempting to open the dialog over a remote session (i.e. via TeamViewer) is difficult.

Running Single Classification Change (Single Tile view in nView):

Shift + M while moving mouse (to open dialog) to change a single defect classification name to any classification name in the drop down (Drop down is based off all defect classes that were present in the model at time of analysis).



Running Group Classification Change (Multi Tile view in nView):

In nView's *Mosaic view*, before clicking and dragging across multiple tiles, hold down *M* button to open dialog.

This will change all the defects in those tiles to the class name chosen in the drop down

Manual Classification
✕

Defect ID: -1

Class Name: Group Manual Classification

Set Class Name: __background__

WARNING: Modifying the defect classifications applies to all defects within the select images, and is irreversible

Cancel Modify

Configurable Light Tower Support

nSpec systems with the light tower assembly can be configured by specifying a *LightTowerConfig.yml* file inside nSpec's *ProgramData/ConfigFiles* directory. Each individual light on the light tower can now blink, remain on, or remain off when a specific nSpec action is performed. Specifically, the following actions are available for configuration:

| State | Trigger Action |
|--------------------------|--------------------------------------|
| <i>ERROR_STATE</i> | Job/scan fails |
| <i>BUSY_STATE</i> | Job/scan is running |
| <i>FREE_STATE</i> | The system is not in any other state |
| <i>UNLOADING_STATE</i> | Job/scan is finished |
| <i>CALIBRATION_STATE</i> | nScan is initializing |

The following lights are available for configuration:

| Light | Note |
|--------|--|
| RED | |
| YELLOW | |
| GREEN | |
| BLUE | Only available on 4/5-color light towers |
| WHITE | Only available on 5-color light towers |

| | |
|-------|--------------------------|
| ALARM | Not a light, but a sound |
|-------|--------------------------|

The following light states are available per light:

| Enumeration | Description |
|-------------|------------------------------------|
| -1 | State of the light will not change |
| 0 | Light will be off |
| 1 | Light will be solid on |
| 2 | Light will be blinking on and off |

The following light states are available per light:

| Enumeration | Description |
|-------------|------------------------------------|
| -1 | State of the light will not change |
| 0 | Light will be off |
| 1 | Light will be solid on |
| 2 | Light will be blinking on and off |

For example, an example action configuration can be the following:

```
ERROR_STATE :
  RED: 0
  YELLOW: 1
  GREEN: 0
  BLUE: 0
  WHITE: -1
  ALARM: -1
```

Sample configurations can be found in this Jira's attachments: [NSPEC-4545](#)

Dual-Flat Bare Wafer Alignment Support

The *Bare Wafer Alignment Wizard* now presents three new different types of fiducial arrangements:

- Dual Flat (180° offset)
- Dual Flat (90° offset)
- Dual Flat (45° or 135° offset)

When any of these options, nScan will use the longer of the two edges when determining the main edge (and consequently, the alignment angle).

Device Inspection on Bare Wafer Support

Device Inspection functionality has been upgraded to support device inspection analysis for bare wafers.

1. The

Bare Wafer Alignment Wizard now has a field for origin offset, which can be used to specify a wafer's origin with respect to the wafer's calculated center in **aligned coordinates** (NSPEC-5413).

1. Device Inspection scan's now accept

Bare Wafer Alignment (.json) files in addition to *Classic Device Inspection* Alignments (NSPEC-5329)

1. Basic Selection analyses will now automatically analyze defects within the device boundaries (NSPEC-5361 adds device boundary detection functionality and NSPEC-5551 makes functionality automatic for device scans).

SECS/GEM Upgrades:

nSpec has introduced several upgrades to its SECS/GEM interface including the following:

| JIRA ID | Description |
|------------|---|
| NSPEC-4816 | OCR ID is now always sent back to GEM host |
| NSPEC-4820 | Events and variables added to indicate wafer positions as they navigate across the cassette, aligner, and stage |
| NSPEC-5420 | Event added to indicate end of scanning; when nSpec is ready to accept more commands |

General Improvements

| JIRA ID | Description |
|------------|---|
| NSPEC-4461 | nSpec's with an interlock system now enforce that the enclosure is locked during nScan initialization |
| NSPEC-4862 | Device IDs are now overlayed onto devices in the Device Layout dialog |
| NSPEC-5241 | Hardware initialization updated to allow parallel loading of independent hardware items |
| NSPEC-5426 | "Advanced" options are now hidden in Bare Wafer Alignment Wizard |
| NSPEC-5570 | Fixed a bug where nSpec would crash when trying to view a deleted analysis group |
| NSPEC-5571 | Fixed a bug where nInstall would leave a 'jobs.dbb' file in ProgramData |

Scanning Improvements

| JIRA ID | Description |
|------------|--|
| NSPEC-5251 | Updated image capture code to greatly improve overall scanning and live view performance |

| | |
|----------------------------|---|
| NSPEC-4550 | <i>UseInitialZ</i> job property now properly prevents the overwrite of the autofocus group's specified offset |
| NSPEC-5194 | Fixed a bug where video sweep would run on the RTX6000 and cause focus to fail |
| NSPEC-5274 | <i>Camera Acquisition Frame Rate Limit (Frames Per Second)</i> program option can be set to free run mode (-1) (SEE Upgrading SECTION) |

Analysis Improvements

| JIRA ID | Description |
|----------------------------|---|
| NSPEC-5550 | Device Inspection analysis performance for large datasets is greatly improved with update to Golden Template Batch Size functionality |
| NSPEC-4333 | Destination folders for golden templates can now be created automatically |
| NSPEC-4406 | Gen3 AI analysis performance for large datasets is greatly improved |
| NSPEC-4669 | Database write times for defects is greatly improved |
| NSPEC-5058 | Fixed a bug where Gen4 analysis would hang on the last image |
| NSPEC-5387 | Fixed a bug where defects found with the Gen4 AI analysis would render at an incorrect orientation |
| NSPEC-5415 | Default value for <i>Golden Template Processing Batch Size</i> has been updated to -1 (automatically determine batch size) |

Autoloader Improvements

| JIRA ID | Description |
|----------------------------|--|
| NSPEC-5139 | Notch detection algorithm greatly improved to accommodate off-center aligner placement |
| NSPEC-5242 | Aligner type is now autodetected (SEE Upgrading SECTION) |

New Features Changelog

| T | Key | Summary |
|---|----------------------------|--|
| | NSPEC-4317 | Remove an exlog during video sweep |
| | NSPEC-4333 | Allow destination folders to be created for a new template during analysis process |
| | NSPEC-4461 | Ensure doors are locked on initialization if enclosure is being used |
| | NSPEC-4545 | Implement Dynamic Light Tower for nSpec |

- NSPEC-4669 Improve DB write times for defect exports
- NSPEC-4721 Return wafers to correct slots when using Find & Return All on Manual Control Dialog
- NSPEC-4745 Add manual classification correction for AI analysis
- NSPEC-4790 Cannot save light controller settings that are not shown in Image Settings Group Dialog
- NSPEC-4816 Always Send OCR ID Back to GEM Host During a Scan
- NSPEC-4820 Add SECS/GEM Event to Notify Host of Wafer Positions
- NSPEC-4835 Scan for Autoloader2 Gen3 Start Position
- NSPEC-4862 Add Device ID to LiveView Boundaries
- NSPEC-4890 Add Ability to Create Masks from GDS Files
- NSPEC-5126 nReg's failure messages should be visible in nLog
- NSPEC-5129 Create User Interface for GDS-based Device Masking
- NSPEC-5139 Notch detection shall be still able to work with small off-center placement
- NSPEC-5145 Add Ability to size masks to multiples of the Camera dimensions
- NSPEC-5154 Add slicing of mask into Device Inspection Analysis
- NSPEC-5155 Add slicing of mask into Mask Creator Dialog
- NSPEC-5241 Update Hardware Manager initialization to allow parallel loading of independent hardware items
- NSPEC-5242 Auto-Detect Autoloader Aligner Type
- NSPEC-5259 Convert Frame Buffer Code to a Concurrent Queue Rather than the Circular Buffer
- NSPEC-5260 Pre-allocate cv::Mat that camera data will be copied to by the callback thread
- NSPEC-5261 Use reference-based snapshot code for Live View





- NSPEC-5274 Update GeniCam frame rate limit Program Option to allow Freerun mode
- NSPEC-5296 Add dilation of mask into Mask Creator Dialog
- NSPEC-5361 Allow Exclusion of non-Device Area for Basic Selection Analysis on Device Inspection Scans
- NSPEC-5370 Extend MESIntegration for Loop Testing/Auto-responses
- NSPEC-5400 Extend Bare Wafer Alignment to Work With Dual-Flat Wafers
- NSPEC-5413 Add Origin Offsets to Bare Wafer Alignments
- NSPEC-5415 Set the default value for Golden Template Processing Batch to -1
- NSPEC-5420 Add SECS/GEM Event for End of Scanning
- NSPEC-5422 Rename "Calibration" to "Objective" in GDS Mask Creator
- NSPEC-5426 Update Bare Wafer Alignment GUI to hide "Advanced" options
- NSPEC-5427 Add Origin Offset to Bare Wafer Alignment GUI
- NSPEC-5472 Automate tile ordering in GDS Mask Creator (tooltip description of tile ordering)
- NSPEC-5476 Update Wizard with Dual-Flat alignment options
- NSPEC-5527 Dilate Pixels text box should not accept values higher than 100
- NSPEC-5551 Remove Basic Selection Analysis Parameter Specific to Device Inspection Scans
- NSPEC-5553 Remove GDS "Create Mask" Option from Device Layout Editor

40 issues

Bug Fixes

Changelog

| T | Key | Summary |
|---|------------|---|
|  | NSPEC-4406 | Gen3 AI analyzer running out of RAM |
|  | NSPEC-4550 | CorrectAfterFirstFocus job property does not work as expected |
|  | NSPEC-4925 | Autoloader3_Gen2 uses incorrect slot number when OCR read fails |
|  | NSPEC-5058 | gen4 analysis freezes on the last image sometimes |
|  | NSPEC-5062 | It takes over 4 minutes to write the db after 40k images DI scan |
|  | NSPEC-5090 | Running a Job From a Database Checks Job Too Late |
|  | NSPEC-5091 | Autoloader Settings From Job Are Not Used When Running Job From Database |
|  | NSPEC-5097 | Mosaic broken when 10x scan and gen4 and 7zip run concurrently |
|  | NSPEC-5194 | Video Sweep runs on RTX6000 and causes focus to fail |
|  | NSPEC-5249 | Alignment error in Create Device Layout dialog causes nScan to crash |
|  | NSPEC-5278 | BSpline and Triangular Mesh Focus Algorithm Undefined Behavior |
|  | NSPEC-5298 | Error message when selecting autofocus group with 'PreFoc' RT algorithm |
|  | NSPEC-5306 | Gen IV Analysis fails due to CUDA exception in Image pipeline |
|  | NSPEC-5321 | "Reporting Export > Output Folder" program option broken |
|  | NSPEC-5329 | Enable Wafer Alignment for DI Scans |
|  | NSPEC-5335 | Condition Variable can produce sync issues with Thread Pool |
|  | NSPEC-5336 | ACS Motor Connection Triggers uncaught exception due to improper use of argument for %s string formatting |
|  | NSPEC-5387 | Gen 4 AI Defects Render at Incorrect Orientation |

-  NSPEC-5409 nSpec does not schedule post scan analysis
-  NSPEC-5412 GDS mask size limit exceeded
-  NSPEC-5423 Entering big number into "Dilate Pixels" text box causes freezing
-  NSPEC-5424 Cannot export a mask in GDS Mask Creator
-  NSPEC-5428 User cannot select layers in GDS Mask Creator
-  NSPEC-5430 nScan crash when creating or loading a Device Layout/GDS
-  NSPEC-5431 GDS Mask Creator creates extra white space
-  NSPEC-5456 Cursor shifts and appends when inserting a value to the GDS edit box
-  NSPEC-5505 Basic Selection (Morphological range) analysis fails
-  NSPEC-5506 Basic Selection (Intensity Exclusive) analysis fails
-  NSPEC-5507 Basic Selection (Intensity Inclusive) analysis hangs
-  NSPEC-5510 Gen3 Writing to Database After Analysis Fails
-  NSPEC-5511 Gen3 Extra Defects Written to DB
-  NSPEC-5512 Precision autofocus fails because of image and template size mismatch
-  NSPEC-5517 When selecting many tiles for group reclassification no "Success" message appears
-  NSPEC-5520 DI analysis does not work
-  NSPEC-5529 gen4 AI analysis fails
-  NSPEC-5530 All PreFocus points have the same exact Z saved to db
-  NSPEC-5533 User can try to save empty mask in 'GDS Mask Creator'
-  NSPEC-5544 Device ID column in image database not populated after BS analysis on DI scan

-  NSPEC-5550 DI analysis fails on GPU with out of memory error for large devices
-  NSPEC-5554 DI scanning freezes with Prefoc 3CP
-  NSPEC-5570 nSpec crashes when viewing a deleted analysis group
-  NSPEC-5571 nInstall adds an extra 'jobs.dbb' to fresh program data
-  NSPEC-5579 Last tile missing from Wafer scan sometimes
-  NSPEC-5599 Memory Leak in Schedule Analysis Dialog
-  NSPEC-5601 No offset applied for Auto/ManualLargeDeviceMask during Precision scan
-  NSPEC-5627 Append "_mask" to Exports
-  NSPEC-5629 Camera and stage angles are not updated when loading a JSON alignment file
-  NSPEC-5641 Frame + Encode/Save thread backups cause missing scan database image rows
-  NSPEC-5647 Detection classes are not written to the scan database properly
-  NSPEC-5691 nScan crashes when attempting to close scan setting dialog

50 issues